Special Issue

Metal Oxide Thin Films: Synthesis, Characterization and Applications

Message from the Guest Editors

Dear colleagues. The last two decades have seen an intensive improvement in thin film deposition methods, enabling the precise coating of surfaces at the nanoscale. Today, it is possible to coat surfaces with complex compositions and synthesize multilayers. The deposition of complex structures allows for the development of new technologies, with recent advances in deposition techniques further miniaturizing electronic devices. The development of these new technologies towards scaling down the size of the produced devices requires accurate control of the deposition process. The latter then allows tailoring thin films and nanodevices to ones desires. This Special Issue will compile recent developments in the field of metal oxide thin film deposition. The articles presented in this Special Issue will cover various topics, ranging from but not limited to the optimization of deposition methods, thin films preparations, the functionalization of surfaces with targeted applications, nanosensors, catalysis, electronic devices, biocidal coating, and the synthesis of nanostructures via the accurate control of thin film deposition methods, among others.

Guest Editors

Prof. Dr. Erwan Rauwel

Institute of Veterinary Medicine and Animal Science, Estonian University of Life Science, Kreutzwaldi 62, 51006 Tartu, Estonia

Prof. Dr. Protima Rauwel

Institute of Forestry and Engineering, Estonian University of Life Science, Kreutzwaldi 56/1, 51014 Tartu, Estonia

Deadline for manuscript submissions

closed (28 February 2021)



an Open Access Journal by MDPI

Impact Factor 3.1 CiteScore 5.8 Indexed in PubMed



mdpi.com/si/24103

Materials MDPI, Grosspeteranlage 5 4052 Basel, Switzerland Tel: +41 61 683 77 34 materials@mdpi.com

mdpi.com/journal/ materials





an Open Access Journal by MDPI

Impact Factor 3.1 CiteScore 5.8 Indexed in PubMed



materials



About the Journal

Message from the Editor-in-Chief

Materials (ISSN 1996-1944) was launched in 2008. The journal covers twenty-five comprehensive topics: biomaterials, energy materials, advanced composites, advanced materials characterization, porous materials, manufacturing processes and systems, advanced nanomaterials and nanotechnology, smart materials, thin films and interfaces, catalytic materials, carbon materials, materials chemistry, materials physics, optics and photonics, corrosion, construction and building materials, materials simulation and design, electronic materials, advanced and functional ceramics and glasses, metals and alloys, soft matter, polymeric materials, quantum materials, mechanics of materials, green materials, general. Materials provides a unique opportunity to contribute high quality articles and to take advantage of its large readership.

Editor-in-Chief

Prof. Dr. Maryam Tabrizian

1. Department of Biomedical Engineering, Faculty of Medicine and Health Sciences, McGill University, Montreal, QC H3A 2B6, Canada 2. Faculty of Dentistry and Oral Health Sciences, McGill University, 3640 Rue University, Montreal, QC H3A 0C7, Canada

Author Benefits

Open Access:

free for readers, with article processing charges (APC) paid by authors or their institutions.

High Visibility:

indexed within Scopus, SCIE (Web of Science), PubMed, PMC, Ei Compendex, CaPlus / SciFinder, Inspec, Astrophysics Data System, and other databases.

Journal Rank:

JCR - Q1 (Metallurgy and Metallurgical Engineering) / CiteScore - Q2 (Condensed Matter Physics)